

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Yan, *et al.* Docket No.: 2003 P 51686 US  
Serial No.: 10/615,630 Art. Unit: 2825  
Filed: July 9, 2003 Examiner: Calvin Lee  
For: Method of Forming Shallow Trench Isolation Using Deep Trench Isolation

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Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

AMENDMENT

Dear Sir:

The following amendments and remarks are presented in response to the Examiner's Office Action mailed June 18, 2004. Please amend the above-referenced application as follows.

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Amendment